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(12) **United States Design Patent**
Lin

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(54) **DOUBLE-LAYER 20-KEY KALIMBA**

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(**) Term: **15 Years**

(21) Appl. No.: **29/733,129**

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(51) **LOC (13) Cl.** **17-01**

(52) **U.S. Cl.**
USPC **D17/7**

(58) **Field of Classification Search**
USPC D17/1, 2, 7, 99; D21/405, 409, 411;
D14/203.1
CPC G10C 1/00; G10C 3/00; G10C 3/12
See application file for complete search history.

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Primary Examiner — R. Johnson

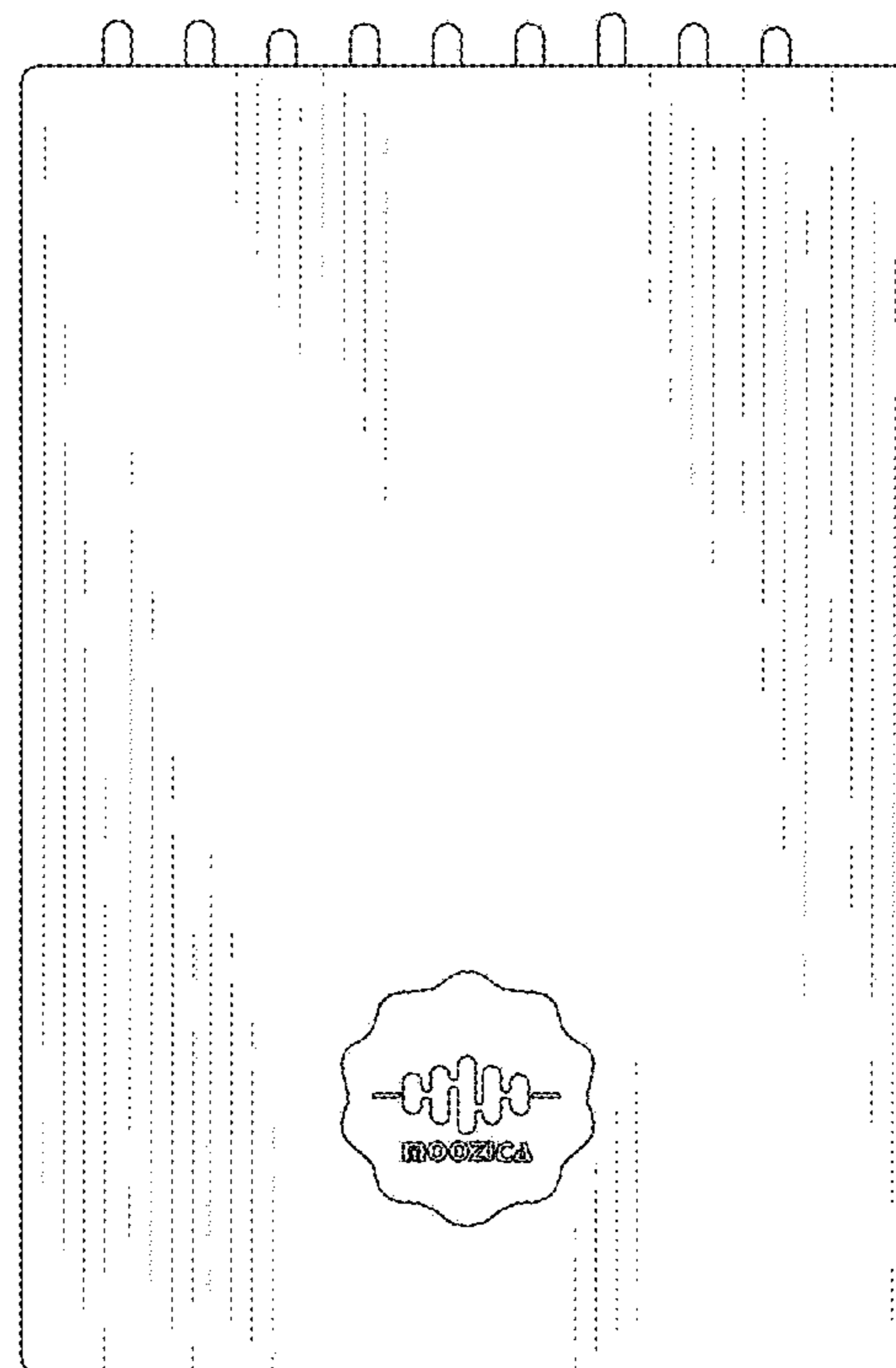
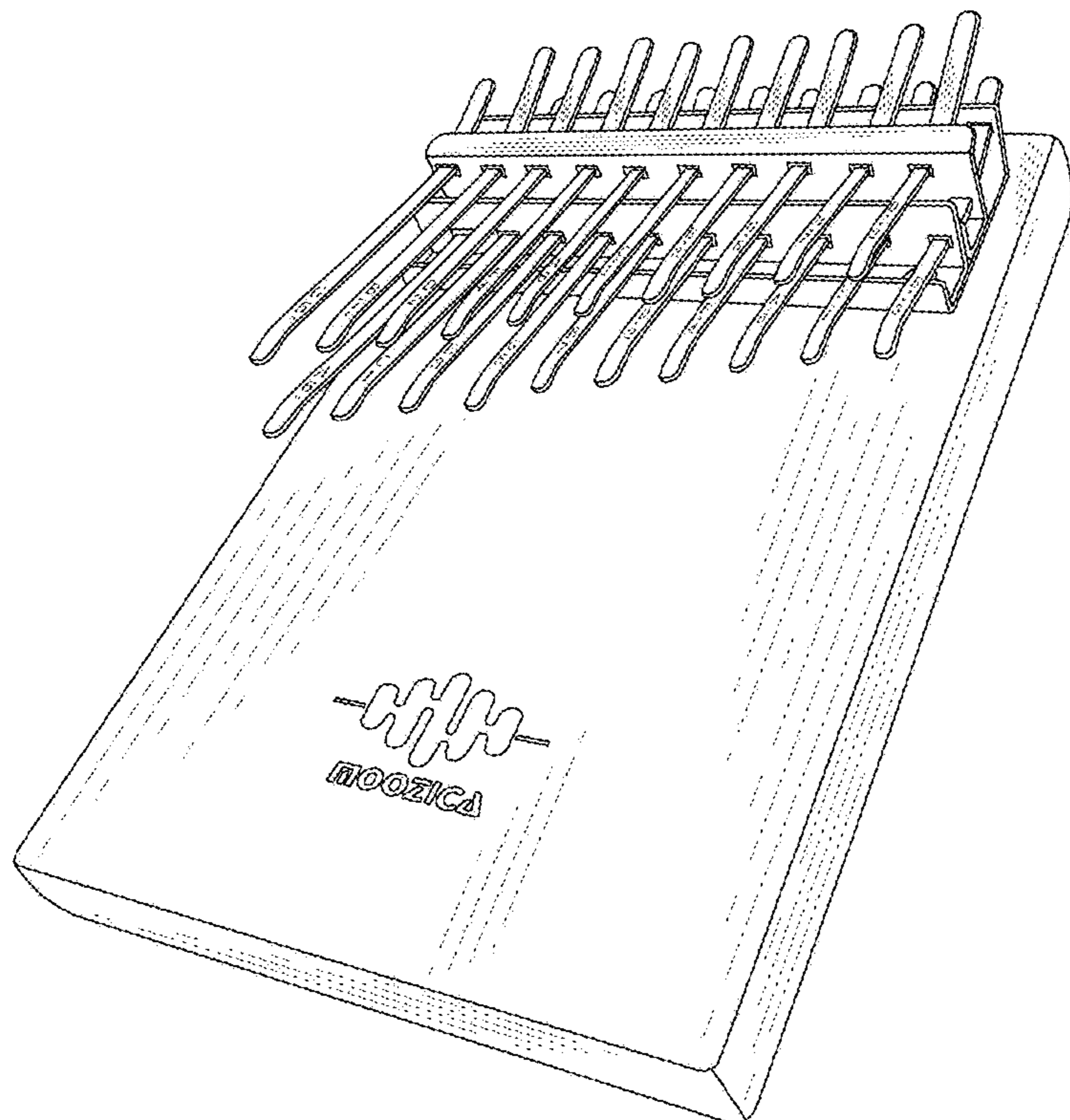
(57) **CLAIM**

The ornamental design for a double-layer 20-key kalimba, as shown and described.

DESCRIPTION

FIG. 1 is a perspective view of a double-layer 20-key kalimba showing my new design;
FIG. 2 is a front elevation view thereof;
FIG. 3 is a rear elevation view thereof;
FIG. 4 is a left side elevation view thereof;
FIG. 5 is a right side elevation view thereof;
FIG. 6 is a top plan view thereof; and,
FIG. 7 is a bottom plan view thereof.

1 Claim, 7 Drawing Sheets



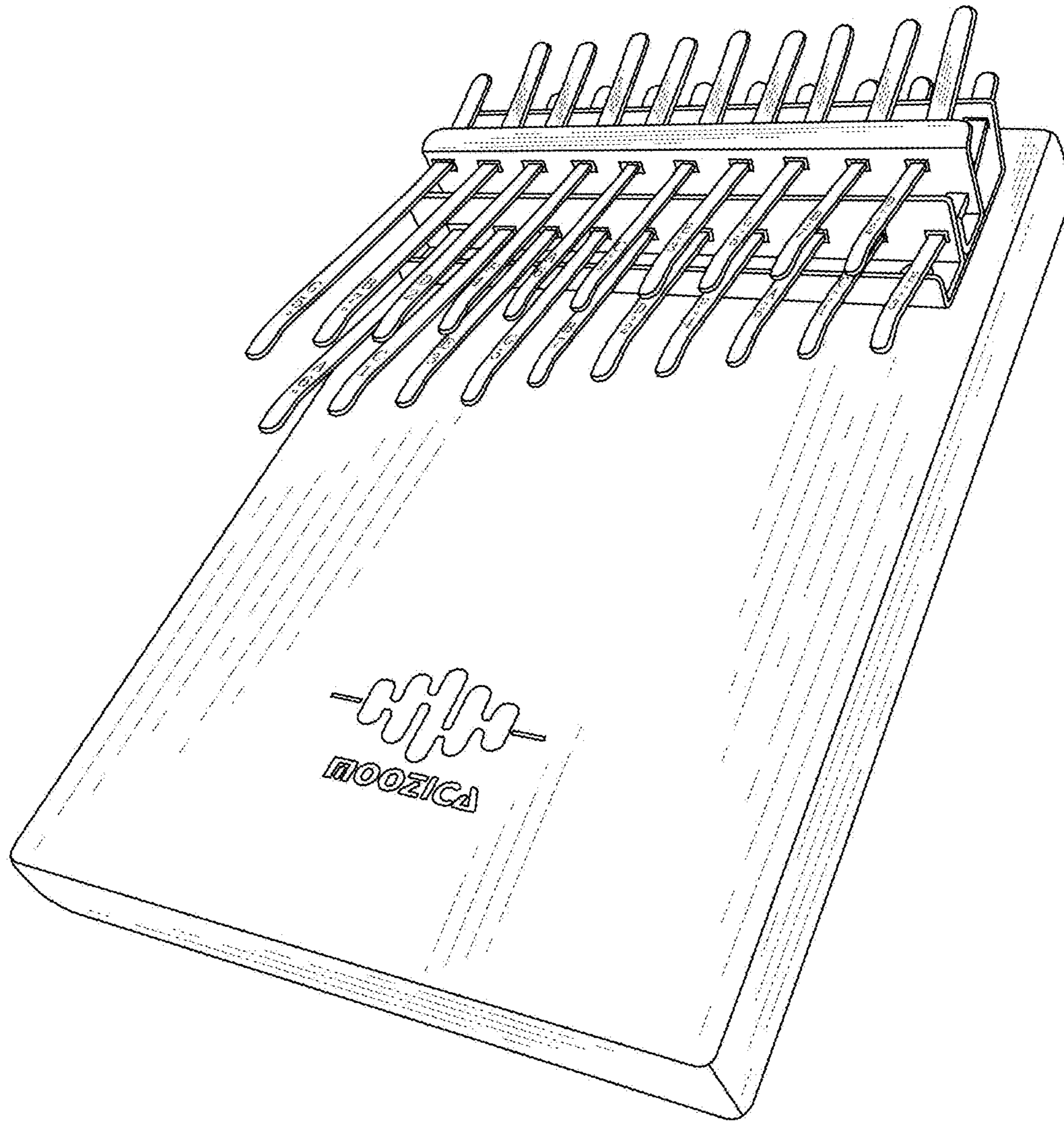


FIG.1

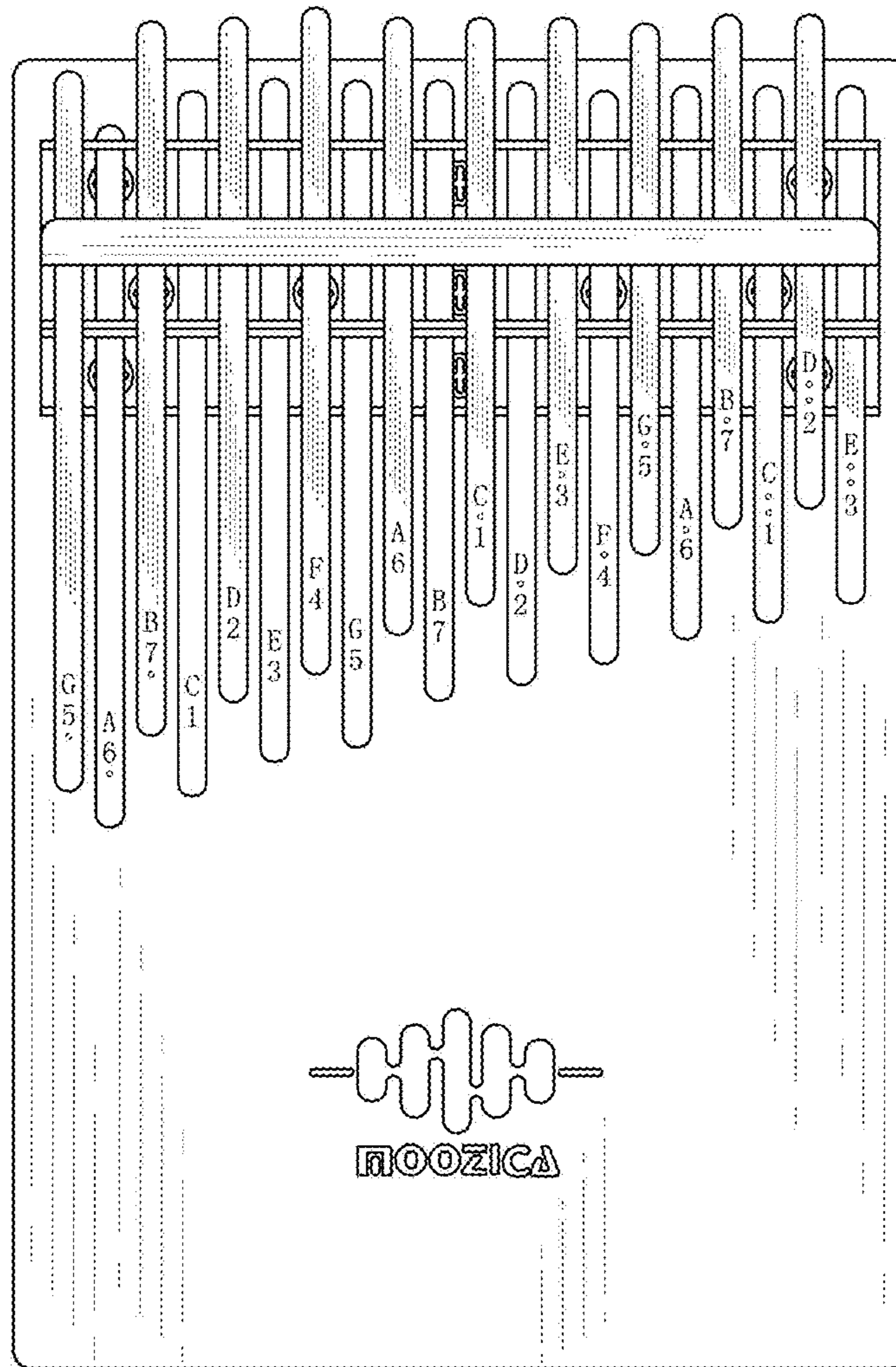


FIG.2

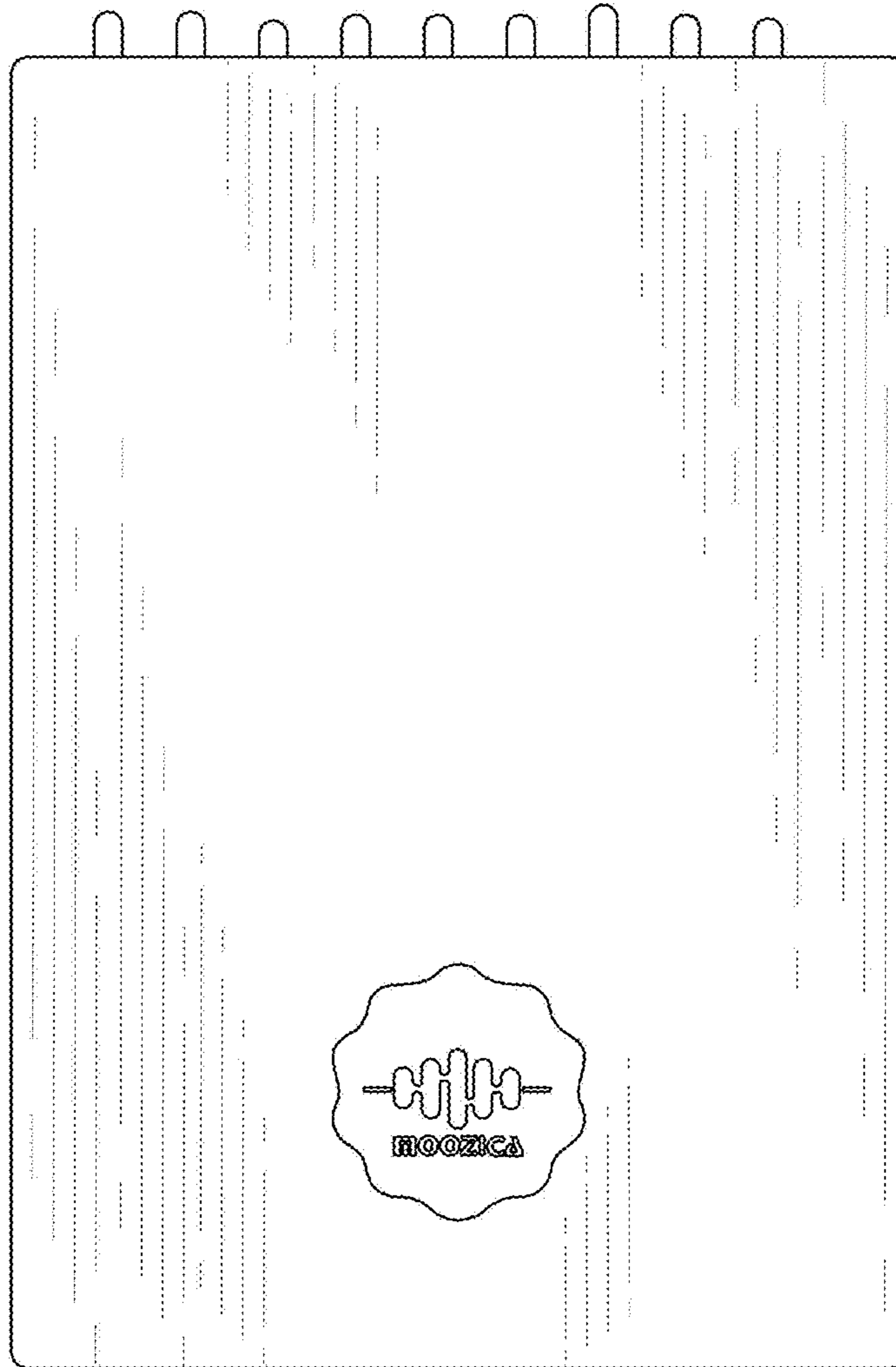


FIG.3

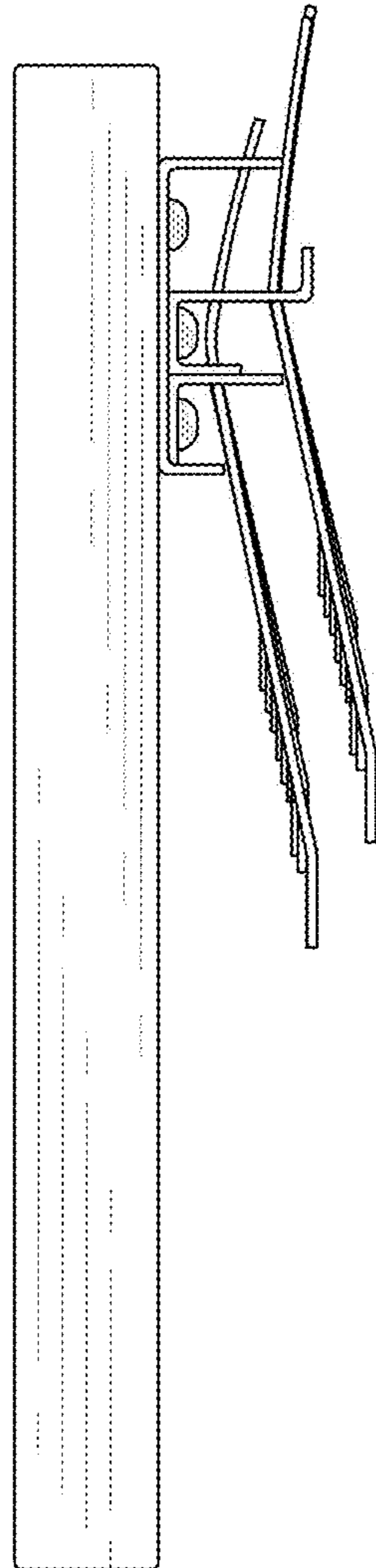


FIG.4

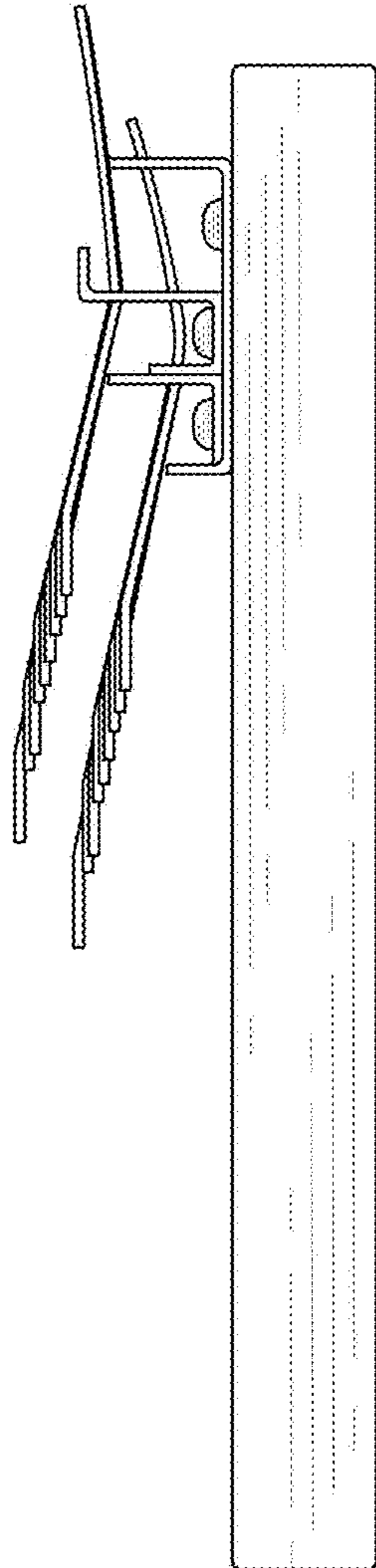


FIG.5

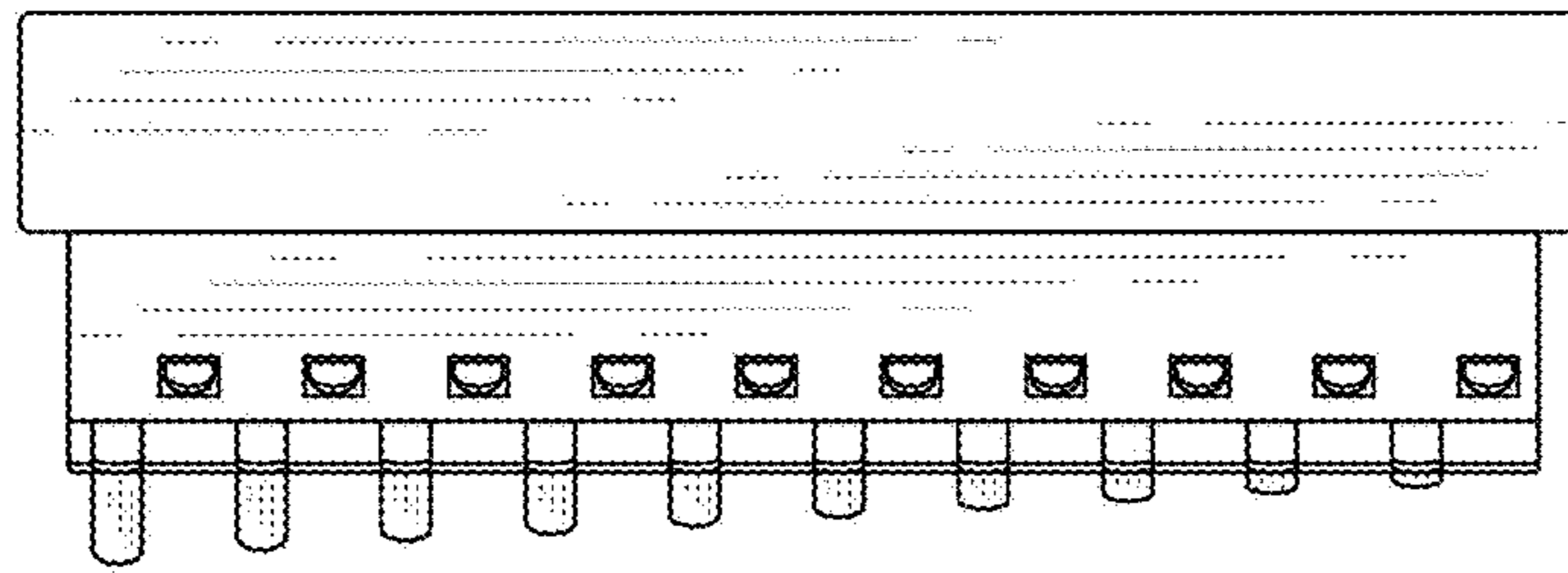


FIG.6

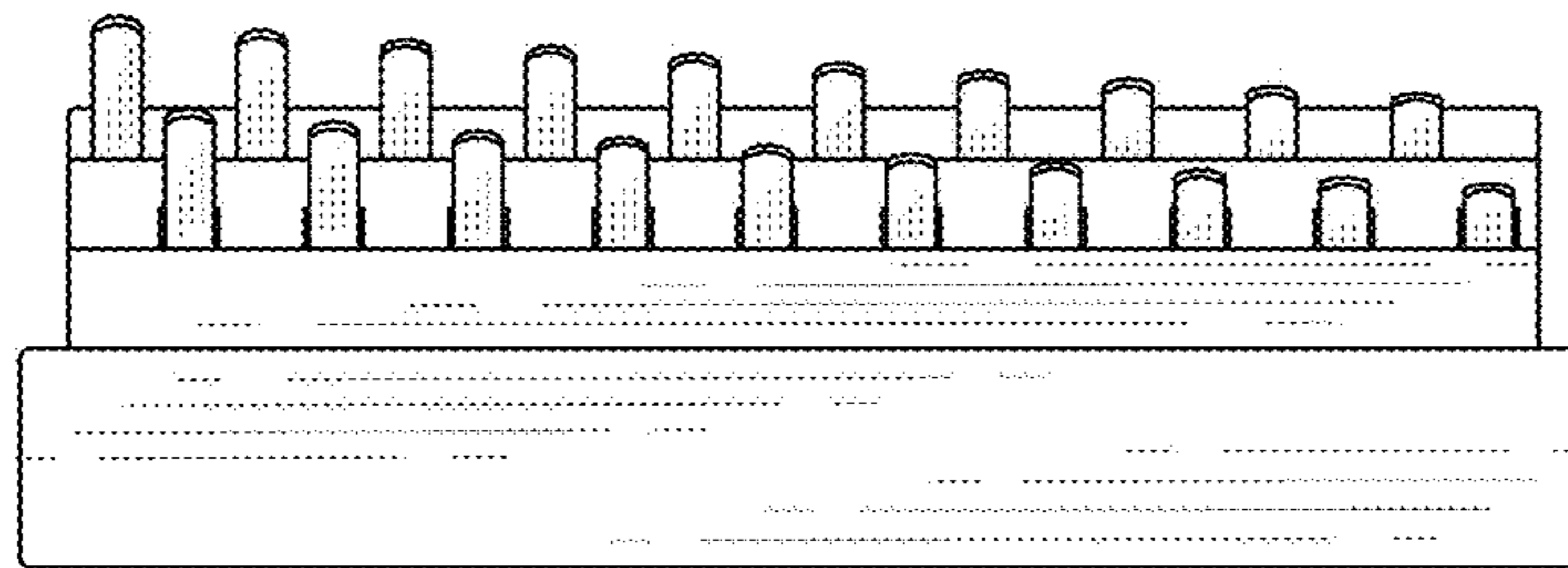


FIG. 7